

Supporting Materials

Ionic memory or electrode artefacts? A systematic assessment of nanofluidic memristors

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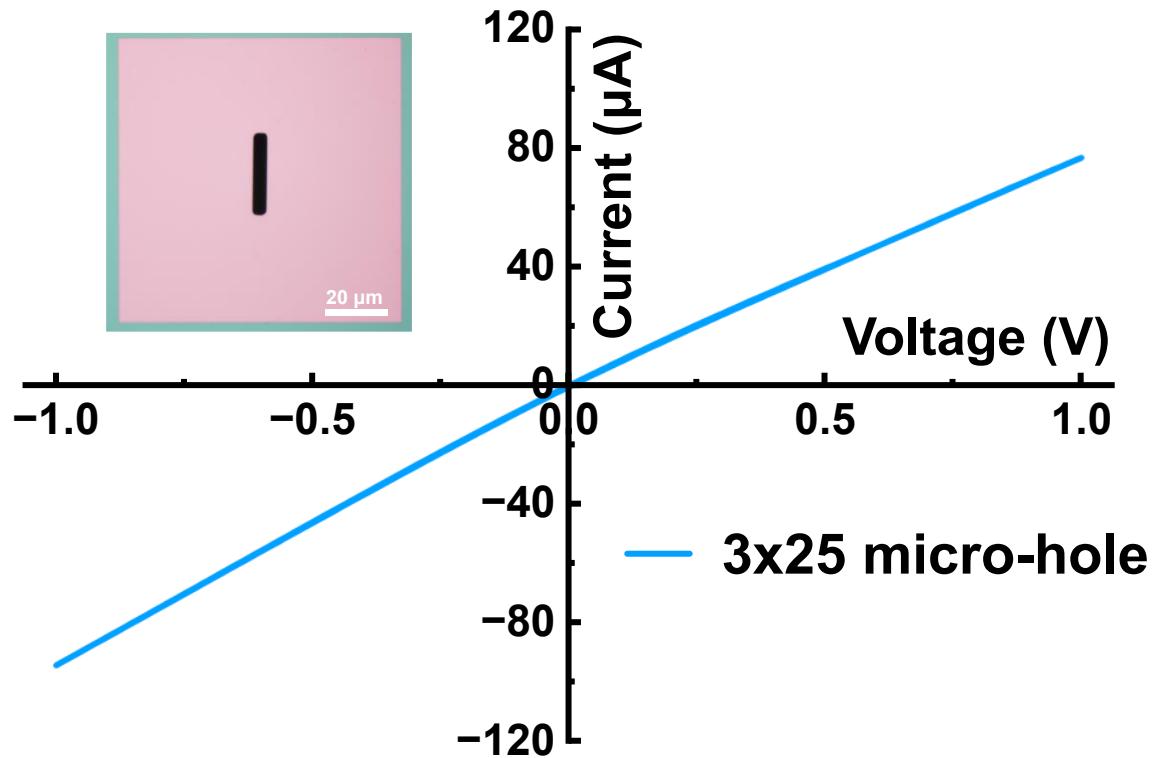
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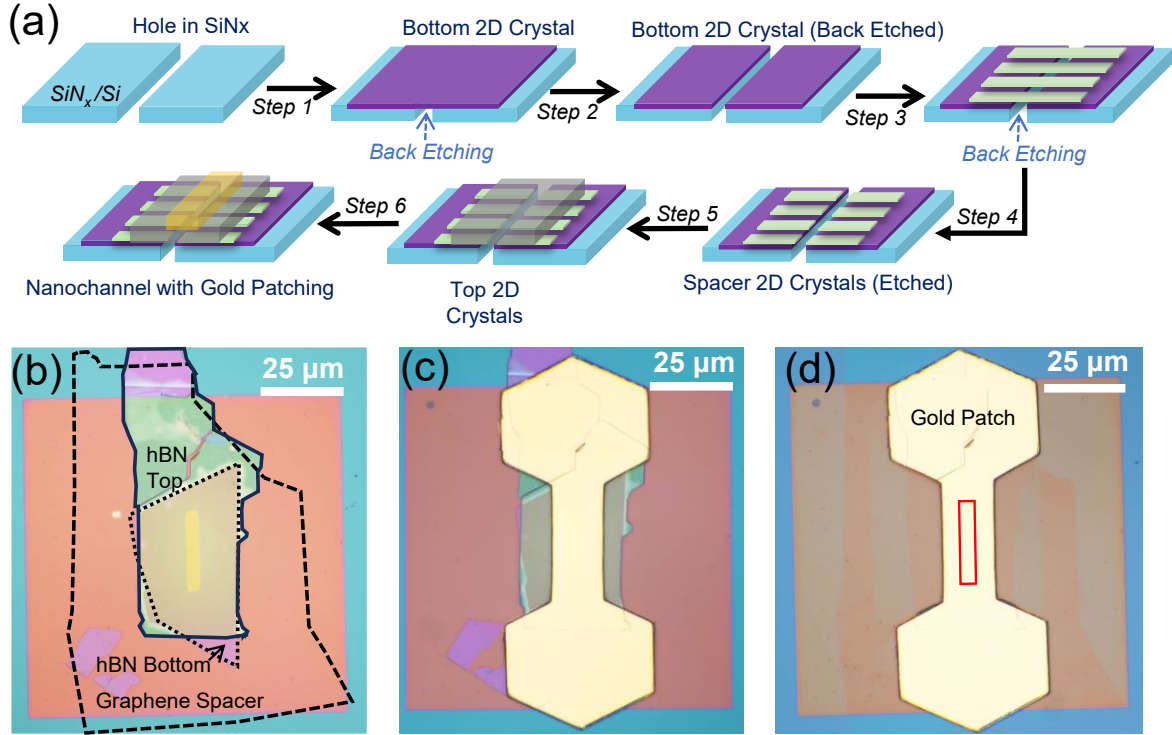
1. Microhole:

We measured ionic currents through a microhole in 1M-KCl solution using Ag/AgCl electrodes, and observed a linear response, without any hysteresis/pinching.



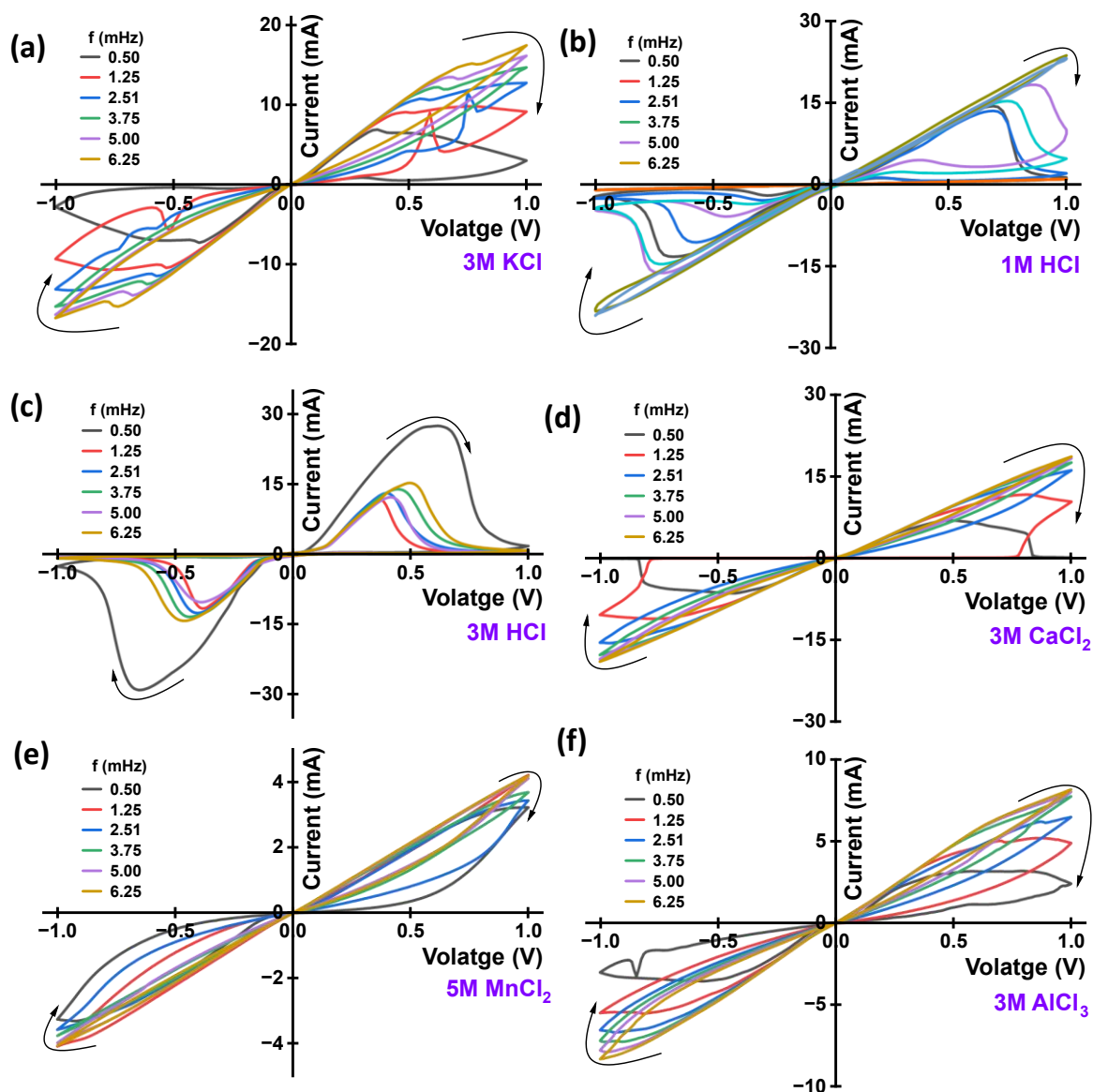
Supplementary Figure 1. I-V characteristics of a 3x25 μm Hole measured using a two-electrode Ag/AgCl configuration within a ± 1 V potential window in 1 M KCl at a sweep frequency of 3.75 mHz. The inset shows the optical image of the microhole.

2. 2D Nanochannel:



Supplementary Figure 2. Fabrication schematic and optical images of 2D nanochannel device. (a) Schematic process flow of device fabrication. A micro-hole is first defined in a freestanding SiN_x/Si membrane by photolithography and reactive-ion etching. Mechanically exfoliated hBN flakes are then used as bottom and top encapsulation layers, with few-layer graphene in between as the spacer. The graphene is patterned by electron-beam lithography and oxygen plasma etching to define ~130 nm-wide channels, and the hBN/Gr/hBN van der Waals heterostructure is assembled. The stacked heterostructure is annealed in 10% H₂/Ar to remove residues and improve interlayer adhesion, after which a Cr/Au patch is patterned and deposited to define the nanochannel length and protect the covered region during subsequent etching of the exposed trilayer. Optical images: (b) of tri-layer stack (hBN-Gr-hBN) on SiN_x free-standing membrane, (c) tri layer stack on SiN_x after Cr/Au deposition, and (d) final nanochannel device after etching exposed region of the trilayer stack. The red color in (d) contours the microhole.

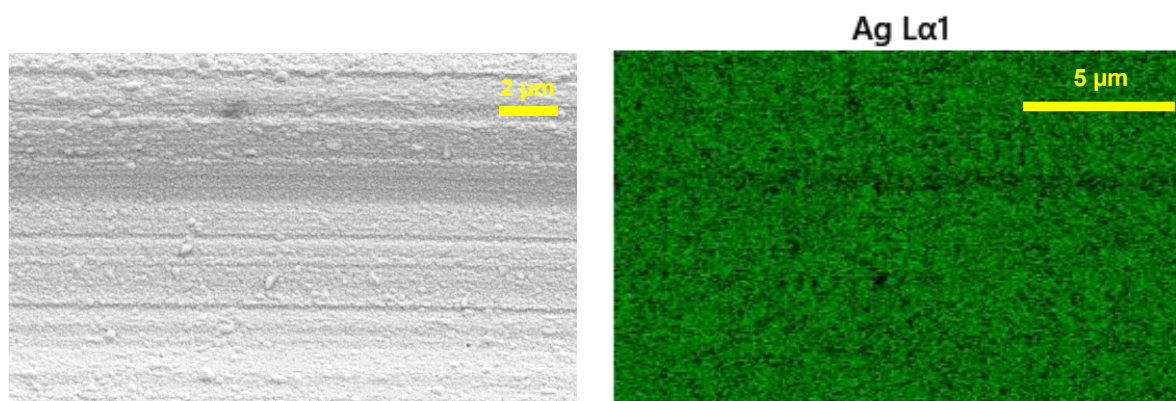
3. Variation of salt type, concentration, and frequency:



Supplementary Figure 3. I-V characteristics of a 100 nm PVDF membrane measured with Ag/AgCl electrodes in different electrolytes and concentrations. Monovalent salts and acid: (a) 3 M KCl, (b) 1 M HCl, (c) 3 M HCl; bivalent salts: (d) 3 M CaCl₂, (e) 5 M MnCl₂; trivalent salt: (f) 3 M AlCl₃. For each electrolyte, the frequency was varied from 0.50 mHz to 6.25 mHz. We observe pinched I-V loops in all of the above salts, and the hysteresis varies significantly with frequency. This demonstrates the strong dependency of the electrochemical response on the applied voltage frequency.

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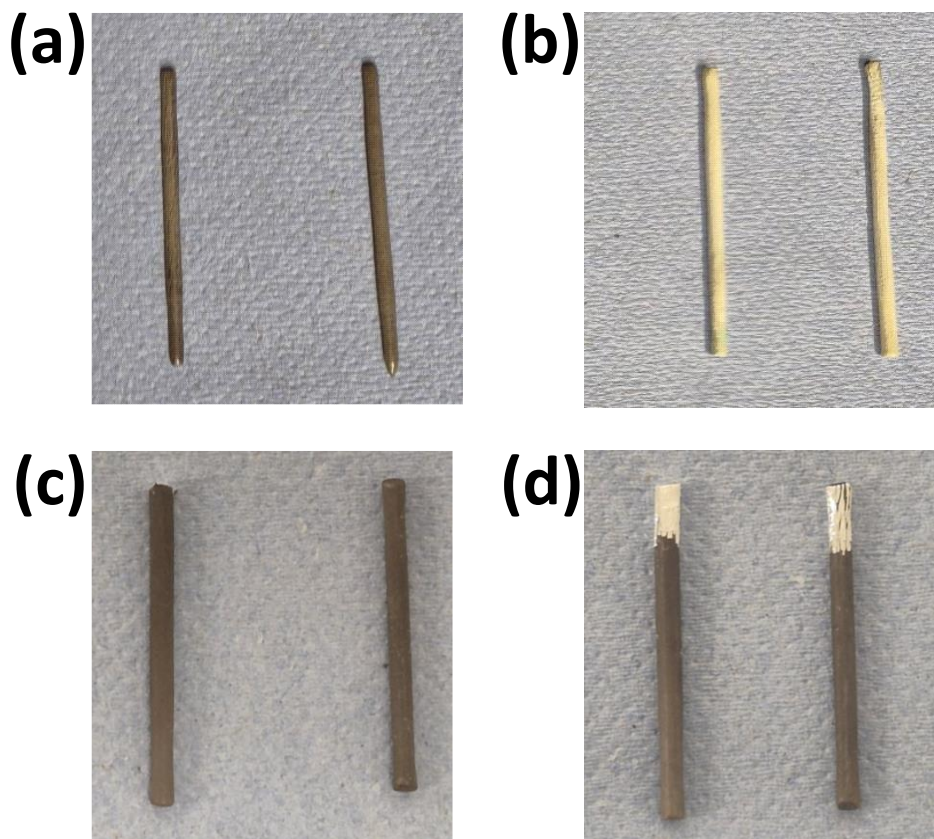
4. SEM and EDX image of Silver (Ag) Rod:



Supplementary Figure 4. Image of Silver (Ag) rod (a) SEM, (b) EDX.

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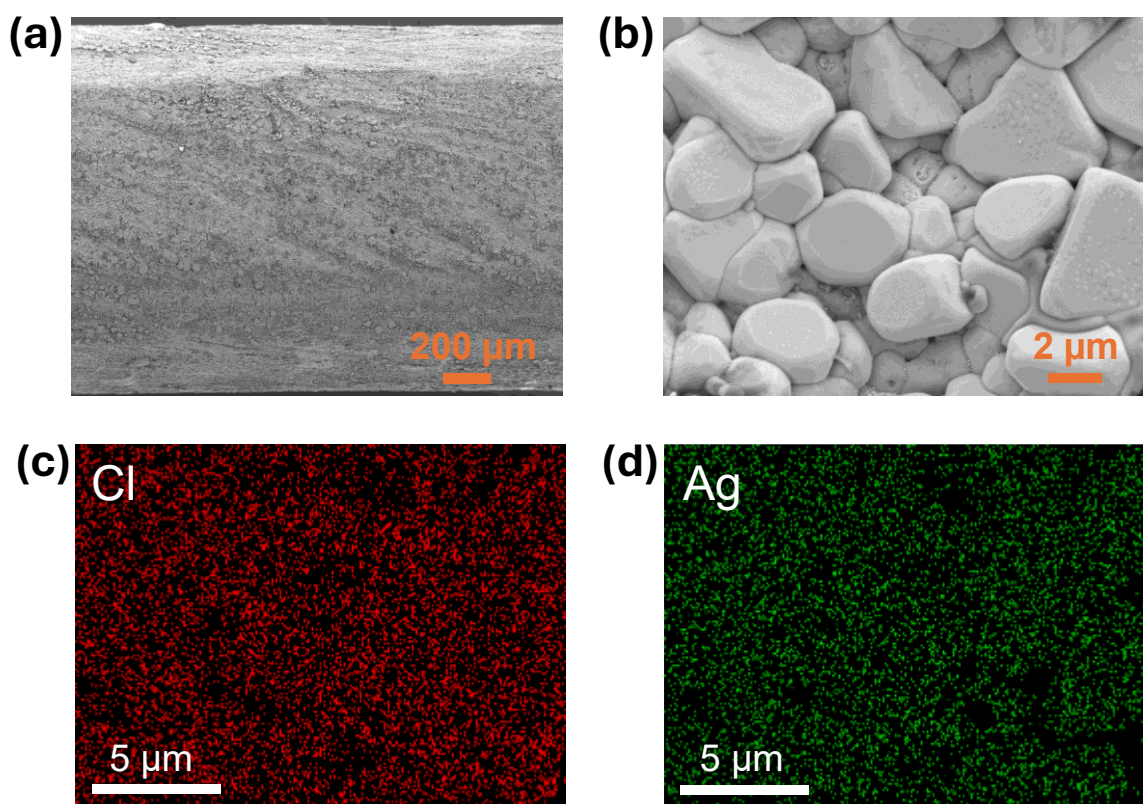
5. Photographs of the electrode before and after 250 cycles:



Supplementary Figure 5. Optical images of Ag/AgCl electrodes. (a) Pristine electrode pair prior to any electrochemical testing. (b) A separate electrode pair after 250 I-V cycles using a PVDF membrane, showing visible colour changes on electrode surface. (c-d) A third electrode pair used for nanochannel I-V measurements: (c) before and (d) after measurements with a bilayer nanochannel device comprising graphene as a spacer and hBN as top and bottom layers. In contrast to (b), no visible surface changes are observed in (d). All measurements were performed in 1 M KCl solution within an applied potential window of 1 V.

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6. SEM and EDX images of Ag/AgCl electrode after 250 I-V cycles with nanochannel:



Supplementary Figure 6. SEM and EDX images of electrode after cycling. (a-b) SEM images of electrode surface acquired at an accelerated voltage of 5KV after 250 I-V cycles with nanochannel. (c-d) EDX elemental mapping in corresponding to obtained SEM image in (b). The IV measurements were performed in 1M KCl within an applied potential window of 1V using a nanochannel device comprising a 2 layer thick graphene spacer stacked between the top and bottom hBN flakes.